

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L7	1146672	magnetic	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/02/13 11:50
L8	82677	trench	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/02/13 11:51
L9	9896	ion adj mill\$3	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/02/13 13:19
L10	574777	resist photoresist	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/02/13 11:52
L11	58225	chemical adj mechanical adj polish\$3 cmp	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/02/13 14:46
L12	489855	planar\$3	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/02/13 11:52
L13	117	L9 and L10 and L11 and L12 and 7 and 8	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/02/13 12:54
L14	0	p3 near3 pedistal	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/02/13 12:54
L15	12	p3 near3 pedestal	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/02/13 12:55
L16	54138	"5" and 11	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/02/13 12:56
L18	2	11 and 15	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/02/13 13:18

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L19	1402	expose near4 magnetic	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/02/13 13:18
L20	12599	plasma adj (etch etching)	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/02/13 13:19
L21	9639	ion adj (mill milling)	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/02/13 13:19
L22	201	19 and (20 21)	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/02/13 13:20
L23	32418	"23" and 11	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/02/13 13:20
L24	107	22 and 11	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/02/13 13:21
L25	68	24 and(alumina AlO3)	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/02/13 13:22
L27	0	partial same fill same magnetic same trench and electroplate	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/02/13 14:42
L28	4	partial same fill same magnetic same trench	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/02/13 14:45
L29	5	partially same fill same magnetic same trench	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/02/13 14:45
L30	753	partially same fill same magnetic	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/02/13 14:45
L31	910	magnetic adj write adj head	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/02/13 14:46

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L32	2	L31 and 30	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/02/13 14:55
L33	16	((("6,693,769") or ("20040027716") or ("20030076630") or ("20040042117") or ("20030202278") or ("6,597,534") or ("6,557,242") or ("6,515,825") or ("6,504,676") or ("20020191350") or ("20020060879") or ("20030169534") or ("6,604,275") or ("6,557,242") or ("20020191350") or ("6,377,423") or ("20020018318") or ("20010005297")).PN.	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	OFF	2006/02/13 14:57
L34	0	33 and electroplate	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	OFF	2006/02/13 14:57
L35	3	33 and electroplating	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	OFF	2006/02/13 14:57
S1	1	("20050193550").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	OFF	2006/02/13 10:21
S2	9896	ion adj mill\$3	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/02/13 10:21
S3	574777	resist photoresist	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/02/13 10:21
S4	58225	chemical adj mechanical adj polish\$3 cmp	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/02/13 10:22
S5	910	magnetic adj write adj head	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/02/13 14:41
S6	74	S2 and S3 and S4 and S5	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/02/13 10:35

EAST Search History

S7	489855	planar\$3	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/02/13 10:35
S8	6643	S7 near5 S4	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/02/13 10:35
S9	22	S8 same S2	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/02/13 11:50
S10	1	("20050057851").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	OFF	2006/02/13 11:34
S11	1	("20050057851").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	OFF	2006/02/13 11:34

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	93367	pedestal	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/13 16:30
L2	26797	write adj head	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/13 16:30
L3	512	1 and 2	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/13 16:31
L4	161985	p2 or p-2 or p adj 2	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/13 16:31
L5	176	3 and 4	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/13 16:31
L6	129009	(p3) or (p-3) or (p adj "3")	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/13 16:32
L7	611	2 and 6	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/13 16:33
L8	59	1 and 7	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/13 16:33

L9	0	2 and 8	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/13 13:09
L10	13	2 and 7	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/13 13:09

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	13	(plasma adj etch or plasma adj etching) and magnetic adj read adj head	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/13 13:08
L2	2278	magnetic adj read adj head	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/13 13:03
L3	54745	cmp	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/13 13:04
L4	42	2 and 3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/13 13:06
L5	2227	expose near4 magnetic	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/13 13:06
L6	16	2 and 5	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/13 13:06
L7	47299	(plasma adj etch or plasma adj etching)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/13 13:08
L8	443	plasma near4 planarization or plasma adj planarize	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/13 13:09